|  | Roll No. [Total No. of Pages 44 |
| :---: | :---: |
| $\infty$ | 7 E 7078 |
| $\theta$ | B. Tech. VII Semester (Main) Examination, Dec. - 2015 |
|  | Electronic Instrumentation \& Control Engg. |
| $N$ | 7EI3A Digital Image Processing |
| Commen with EC |  |

Time: $\mathbf{3}$ Hours
Maximum Marks : $\mathbf{8 0}$
Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly.
Unit - I

1. a) Discuss operation and working of CCD sensors.
b) What are important image file formats? Discuss their key features briefly. (8)

## OR

1. a) Write coordinate equations for zooming operation \& Discuss it briefly by taking a suitable example.
b) Briefly discuss the following
i) Spatiol racclution of an imana
ii) HSI color model

## Unit - II

2. a) Discuss Gamma correction used for contrast enhancement of under exposed and over exposed images. Show it by drawing suitable Gamma-correction curves.

## Unit - V

5. a) Discuss gradient operators in context to two-dimensional images. Write $3 \times 3$ region two-dimensional sobel masks and express their partial derivative equations.
b) Compare loss-less versus lossy compression techniques and state about some well known standards for both of these techniques.

## OR

5. a) Discuss differential PCM based image compression by drawing its block diagram.
b) Discuss Transform based image compression technique and state about a popular compression standard based on this technique.


Time: $\mathbf{3}$ Hours
Maximum Marks : 80
Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly).

## Unit - I

1. a) Prove that the total power radiated by a Hertz Antenna is given by

$$
\begin{equation*}
W=40 X^{2} I_{0}^{2}\left(\frac{d l}{\lambda}\right)^{2} \tag{10}
\end{equation*}
$$

b) If a dipole antenna of maximum dimension $\mathrm{D}=20 \mathrm{~cm}$ has to radiate a signal of 20 MHz then find the distance from this antenna
i) Up to which its array element can be placed.
ii) After which a receiving antenna can be placed

## OR

1. a) What is antenna polarization? Describe its types and state its relation with the physical orientation of transmitting antenna. If the radiated field from an antenna


$$
(2+3+3=8)
$$

b) Define the following and find their value for an antenna has physical length $=20 \mathrm{~m}$, operating frequency 200 MHz and placed in ambient temperature of $300^{\circ} \mathrm{k}$.
i) Antenna effective length
ii) Antenna aperture
iii) Antenna temperature.
iv) Antenna radiation resistance
[Contd....
2. a) Design a two element antenna array to be working as broad side array at 30 MHz
b) State the conditions for non uniform antenna array. Give four example of such antenna array which are practically used in communication.
c) If the phase between two elements in an antenna array of N -sources (all uniform) can changes from $0^{\circ}$ to $180^{\circ}$ then find the rotation of principal maxima

## OR

2. a) Find the $3-\mathrm{dB}$ beam width for an antenna array having 20 uniform elements placed at a separation of $\lambda / 4$ and operating at 200 MHz
b) Explain the principle of pattern multiplication. Does this principle can be used for design an antenna array in which no side lobe is there. If yes then give such example
c) Write the classification of antenna array and state the classification type for i) Yagi uda antenna and
ii) Log periodic antenna.

## Unit-III

3. a) Draw the structure of following antenna and write their frequency operation and specific use.
i) Microstrip patch antenna
ii) Folded dipole
iii) Rhombic antenna
iv) Parabolic reflector.
b) Design a log periodic antenna having maximum 10 element and working at 100 MHz . Find its maximum horizontal and vertical dimension

OR
3. a) Draw the different waveguide antenna and explain their radiation pattern operating frequency and state of polarization
 setup is applicable for all frequency range?
c) Find the input resistance of a 3 element loop antenna. Let the impedance of each isolated element is $100 \Omega$

Unit-IV
4. a) Calculate the maximum usable and critical frequency for
i) D-layer having ion density $10^{12} / \mathrm{m}^{3}$
ii) F-layer having ion density $10^{14} / \mathrm{m}^{3}$

- b) Calculate the minimum vertical length of a receiving antenna which is receiving a line of sight signal from a transmitter placed at 30 Km distance and placed 30 meter above ground. Assume the operating frequency is 200 KHz .
c) State the nature of reflected wave from ground when the incident wave is
i) Plane polarized and
ii) Circularly polarized.


## OR

4. a) Define the following wave phenomena
i) Reflection from ionosphere
ii) Reflection from conductor
iii) Scattering in troposphere
iv) Refraction at interface of D \& E layer
b) Explain the effects of
i) Ground conductivity and
ii) Earth curvature on wave propagation

Unit -V
5. a) What is solar activity? How it effect wave propagation. Can be use these periodic solar activity for improve the performance of communication system? If yes then explain how?
b) What is Faraday rotation? What is the source of faraday rotation? How it effects wave propagation
c) How electrical properties of atmospheric layer charges with seasons.

## OR

5. a) If two atmospheric layer has ionization density $10^{12}$ and $10^{14} / \mathrm{m}^{3}$ then find the angle of refraction at their interface if the incident angle is $45^{\circ}$
b) What is correlation between total intemal reflection and ionospheric reflection. What is the incident angle for a 15 MHz signal which has to reflected back from a layer at 3 Km above and having ion density $10^{15} / \mathrm{m}^{3}$.
c) What is virtual height? How it changes antenna actual height?

Maximum Marks : $\mathbf{8 0}$
Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly.)

## Unit - I

1. a) A DSSS system has a 1.2288 Mcps code clock rate and a 9.6 kbps information rate. Calculate the processing gain. How much improvement in information rate is achieved, If the code generation rate is changed to 5 Mcps and The processing gain to 256 ?
b) Explain the properties of spreading codes. How they are generated, briefly explain?

## OR

1. a) Explain DSSS with BPSK with neat diagrams, and write the properties of DSSS.
b) Compare FHSS with DSSS.
c) In an FHSS system, a Hopping band width of 100 MHz and a frequency spacing of 10 KHz are used. What is the minimum number of PRN chips are required for each frequency symbol?

## Unit - II

2. a) What is small scale fading? Write the factors influencing fading.
b) The discrete power delay profile for multipath transmission is shown in figure calculate multipath power gain, mean delay and r.m.s delay spread


## OR

2. a) Explain the concept of diffraction loss as a function of path difference around an obstruction by fresnel zones.
b) Describe the free space propagation path model, when is two-ray propagation model suitable.
Unit - III
3. a) Explain the principle of operation of CDMA.
b) What is near far nroblem in CDMA?
c) What is rake receiver? How it is useful for CDMA reception? Explain briefly.(7)
d) Define soft Hand off.
4. a) Define TDMA frame structure and efficiency of TDMA systems.
b) Explain the basic principle of operation of OFDM technique and write its advantages and disadvantages.
c) A normal GSM time slot consists of 6 trading bits, 8.50 guard bits, 28 training bits and 2 traffic bursts of 58 bits of data, find the frame efficiency.

## Unit - IV

4. a) Write the advantages and disadvantages of wireless local area network. Briefly explain the IEEE 802.11 standards.
b) Write the short note on RFID Technology.
c) IEEE 802.11 WLAN system operates at 2 Mbps . Determine the data transfer time of a 20 kb file.

## OR

4. a) Explain the different physical and control channels in GSM.
b) Draw and explain the frame format for GSM.
c) Compare wifi and Wi-max Technology.
Unit - V
5. a) Explain the process of Link design of a satellite system and derive an expression for the received power.
b) What are the satellite subsystems? Draw a diagram of AOCS and explain. (8)
OR
6. a) Draw a neat diagram telemetry, tracking, command and monitoring system for successful operation of a communication satellite and explain it.
b) Write the short note on components of earthstation.

## 7E7084

B.Tech. VII Semester (Main) Examination, Nov. - Dec. 2015 Electronics \& Communication Engg. 7EC5A VLSI Design

Time : $\mathbf{3}$ Hours

Maximum Marks : 80
Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly).

## Unit - I

1. a) Demonstrate CMOS n-well fabrication process using diagram for each step.
b) The PMOS and NMOS transistors in the given figure are matched with $K_{n}^{\prime}\left(\frac{W_{n}}{L_{n}}\right)=K_{p}^{\prime}\left(\frac{W_{p}}{L_{p}}\right)=1 \mathrm{~mA} / \mathrm{v}^{2}$ and $\mathrm{V}_{\mathrm{tm}}=-\mathrm{V}_{\mathrm{tp}}=1 \mathrm{~V}$. Assuming $\lambda=0$ for both the devices, find the drain currents $\mathrm{I}_{\mathrm{DN}}$ and $\mathrm{I}_{\mathrm{DP}}$ and voltage $\mathrm{V}_{0}$ for $\mathrm{V}_{\mathrm{I}}=2.5 \mathrm{~V}$


## OR

1. a) Drive the expression of $I_{D 1}-V_{D S}$ relation for enhancement type MOSFET. Also calculate/drive the channel length modulation parameter
b) An inverter fabricated in a $1.2 \mu \mathrm{~m}$ CMOS technology uses the channel length $\mathrm{L}_{\mathrm{n}}=\mathrm{L}_{\mathrm{p}}=1.2 \mu \mathrm{~m}$. If $\mathrm{w}_{\mathrm{n}}=1.8 \mu \mathrm{~m}$, Find the value of Wp that will result in NMOS \& PMOS being matched. Calculate the output resistance of inverter when $\mathrm{V}_{0}=\mathrm{V}_{\mathrm{OL}}$, For this given that $k_{n}^{\prime}=80 \mu A / V^{2}, k_{p}^{\prime}=27 \mu A / V^{2}, \mathrm{~V}_{\mathrm{tn}}=0.8 \mathrm{~V}$ and $V_{D D}=5 \mathrm{~V}$.

## Unit- II

2. a) Implement the boolean expression $Y=\overline{(D+E+A)(B+C)}$ using CMOS logic. If $\left(\frac{W}{L}\right)_{n}=10$ and $\left(\frac{W}{L}\right)_{p}=15$, then find the equivalent $\left(\frac{W}{L}\right)$ ratio of pullup network and pull down network.
b) Consider a CMOS inverter with following parameters
$\mathrm{V}_{\mathrm{DD}}=3.3 \mathrm{~V}, \mathrm{~V}_{\mathrm{tn}}=0.6 \mathrm{~V}, \mathrm{~V}_{\mathrm{tp}}=-0.7 \mathrm{~V} . \mathrm{K}_{\mathrm{n}}=200 \mu \mathrm{~A} / V^{2}, \mathrm{~K}_{\mathrm{p}}=80 \mu \mathrm{~A} / V^{2}$. Calculate the noise margins of the circuit.

## OR

2. a) Discuss the short circuit power dissipation in a CMOS circuit . Derive the expression for total power dissipation
b) Consider a CMOS inverter with following parameters, $\mathrm{V}_{\mathrm{t}}=0.6 \mathrm{~V}$, $\mu_{n} C_{o x}=60 \mu A / V^{2}\left(\frac{W}{L}\right)_{n}=8, V_{\text {tp }}=-0.7 \mathrm{~V}, \mu_{p} C o_{x}=25 \mu A / V^{2},\left(\frac{W}{L}\right)_{p}=12$ Calculate
the noise margins and switching threshold of the circuit, the power supply voltage $\mathrm{V}_{\mathrm{DD}}=3.3 \mathrm{~V}$.

## Unit - III

3. a) Draw the eular's patin and layout for CMOS implumentation of buoleaii function $\bar{Y}=\bar{a} b+c+D$
b) Implement the given expression using pass-transistor logic $Y=\bar{a} b+\bar{b} c+\bar{c} a$ also draw its layout also.

## OR

3. a) Draw the model for physical organization of latch-up problem. Draw its V-I characteristics of this circuit and explain how latch-up triggers.
b) Write necessary condition for latch-up prevention. Describe minimum three eschniques for preventing internal and I/O latch-up

## Unit - IV

4. a) Draw the circuit diagram of 4-transistor DRAM cell . Explain its read and write operation.
b) How zipper CMOS logic differs from Domino CMOS logic. Write the difference in gate implementation and performance

OR
4. a) Draw generalised circuit/block diagram of RAM.Explain read and write operation of a RAM cell using timing diagram
b) Compare clocked CMOS logic and dynamic CMOS logic for their implementation and performance.

Unit - V
5. a) Write VHDL code for edge triggered S-R Flip-Flop in behavioural style using process statement.
b) Write a brief note on front-end and back-end ECAD tools used to design VLSI circuits.

## OR

5 a) Differentiate custom $I_{c}$ and application specific $I_{c}$ (ASIC)
b) Draw/write ASIC design flow graph and explain
c) Write VHDL code to realize full adder using Half adder in structural style. (8)
B.Tech. VII Semester (Main) Examination Nov./Dec.- 2015

## Electronics \& Communication Engg .

## 7EC6.3A VHDL

Time: 3 Hours

Maximum Marks : 80<br>Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly.

## Unit - I

1. a) Draw the schematic design flow of ASICS and standard logic circuit and explain it.
b) What is VHDL? Explain how variables, signal and constants are declared and used inVHDL.

## OR

1. Explain the following.
a) Different types of PLD.
b) Placo and routandtiming cimulation.

## Unit - II

2. a) Briefly explain history of HDL and compare various hardware description language.
b) Explain data flow, structural, behavioral, and RTL Style of combinational design.

## OR

2. a) Explain event driven simulation and simulation approaches .
b) Explain elaboration signal drivers simulator kernel process.

## Unit - III

3. a) Define multiplexer. How an $16 \times 1$ mux can be implemented using two $8 \times 1$ mux?
b) Write VHDL code for 4 - bit comparator

## OR

3. a) Write structural VHDL description for n-bit serial - in - serial out shift register.
b) Write a VHDL description for S-R latch
i) Use two logic gates.
ii) Use a characteristics equation
iii) Use a conditional assignment statement.
Unit - IV
4. a) Draw block and state diagram of vending machine
b) Derive the state diagram for an FSM that has input ' $W$ ' and output ' $Z$ '. The machine has to generate $z=1$, when the previous four values of W were 1001 or 1111 else O. Overlapping input patterns are not allowed. Write VHDL codefor above FSM.
OR
5. a) What are difference between mealy and Moore types of FSM
b) Explain Moore types FSM using state diagram, state table and state assigned table.

## Unit - V

5. a) Draw the schematic diagram for the data path circuit for the divide operation.
b) Briefly explain the clock synchronization
(8)

OR
5. Write short notes on:
a) SRAM
b) Shifting and sorting operation.

## 7E4047

## B.Tech. VII Semester (Back) Examination, Dec.- 2015

 Electronics \&Communications.
## 7EC4(O) I.C Technology

Time: $\mathbf{3}$ Hours

Maximum Marks : 80<br>Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly.)

## Unit - I

1. a) Mention the types of defects and their effects in a semic aductor material.(8)
b) Write steps to obtain E.G.S. from M.G.S. Also mention considerations for proper crystal growth .

## OR

1. a) Briefly describe characterization \& evaluation techniques for crystals .
b) Mentioning the principle involved in Czochralski growth process, describe the interpretation of the equation given below:

$$
\begin{equation*}
\mathrm{H}_{\mathrm{o}}-\mathrm{H}_{\mathrm{i}}=\operatorname{AL} \rho(\mathrm{dx} / \mathrm{dt}) \tag{8}
\end{equation*}
$$

## Unit - II

2. a) Prove that the effect of field erhancement factor is to (atmost) double the magnitude of the diffusivity under field - free conditions.
b) With reference to the process of Ion implantation briefly describe the following:
i) Nuclear and electronic stopping.
ii) Range and annealing.

## OR

2. a) Derive due expressions to describe the kinetics of oxide growth.
b) Discuss the properties of thermal oxides of silicon.

## Unit - III

3. a) With reference to epitaxy process, describe briefly the following :
i) Autodoping .
ii) Slip.
iii) VPE.
iv) MPE.
b) Mention evaluation techniques of epitaxial layers.

OR
3. a) How does low pressure chemical vapor deposition differs from normal chemical vapor deposition process.
b) Describe CVD process for deposition of dielectric \& polysilicon.

## Unit - IV

4. a) Mention the properties of photoreactive materials .
b) What is meant by Image reversal with reference to photolithography .Also describe printing techniques.

OR
4. a) Compare optical and electron beam lithography from following aspects:
i) Complexity
ii) Cost
iii) Speed / yield
iv) Resolution.
b) Compare wet etching and reactive ion etching.

## Unit - V

5. a) What is meant by bird beaks in the process of locos. Suggest one method to remove the above mentioned bird beaks .
b) What is meant by planarization why and how we obtain planarizations.
OR
6. a) What are the various objectives surved by the process of metallization, describe them briefly.
b) Mention all the steps required to fabricate a bipolar IC.
(8)

## B.Tech. VII Semester (Back) Examination, Dec. - 2015

## Electronics \& Communication Engg.

 7EC5(0) VLSI Design
## Time : $\mathbf{3}$ Hours

Maximum Marks : 80
Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly.

## Unit - I

1. a) Calculate the threshold voltage $\mathrm{Ve}_{0}$ for a polysilicon gate n -channel MOS transistor with following parameters:

$$
\begin{array}{ll}
\text { Substrate doping density } \mathrm{N}_{\mathrm{A}} & =10^{18} \mathrm{~cm}^{-3} \\
\text { Polysilicon gate doping density } \mathrm{N}_{\mathrm{D}} & =10^{20} \mathrm{~cm}^{-3} \\
\text { Gate oxide thickness } \mathrm{t}_{\mathrm{ox}} & =1000 \mathrm{~A}^{0} \\
\text { Assume oxide interface fixed charges } & =\text { nil }
\end{array}
$$

b) Write the Fabrication steps difference between NMOS and CMOS
c) Define Accumulation phenomenon in MOS structure.

## OR

1. a) Draw the structure of depletion mode transistor. Also draw the fabrication stenc to ohtained this structure.
b) Draw the Energy band diagram of MOS capacitor structure under following conditions
i) Accumulation
ii) Depletion and
iii) Inversion

## Unit - II

2. a) Find the $V_{g s_{n}}, V_{g s_{p}}, V_{d s_{n}}$ and $V_{d s_{p}}$ in a CMOS inverter when I/P is
i) $\quad V_{\text {in }}=0$ volt
ii) $\mathrm{V}_{\text {in }}=1.5 \mathrm{~V}$
iii) $\mathrm{V}_{\text {in }}=3.5 \mathrm{~V}$ and
iv) $\mathrm{V}_{\mathrm{in}}=4.8 \mathrm{~V}$

Assume $\mathrm{V}_{\mathrm{DD}}=5 \mathrm{~V}$ and $\mathrm{V}_{\mathrm{Tn}}=\left|V_{T P}\right|=0.8 \mathrm{~V}$
b) What is body-effect? Discuss the effects of body-bias on
i) Threshold voltage $V_{T}$ and
ii) $\mathrm{I}_{\mathrm{ds}}-V_{\mathrm{ds}}$ characteristics

## OR

2. a) Design a resistive load NMOS inverter for obtain $\mathrm{V}_{\mathrm{OL}}=0.5 \mathrm{~V}$. Assume $\mathrm{V}_{\mathrm{DD}}=5 \mathrm{~V}, K_{n}^{\prime}=300 \mu \mathrm{~A} / \mathrm{V}^{2}$ and $\mathrm{V}_{\text {TO }}=0.0 \mathrm{~V}$
b) Draw the MOS transistor circuit model at low frequency, and discuss its all
parameter.

## Unit - III

3. a) Draw the following circuits
i) $\mathrm{y}=A \bar{B} C$ Using CMOS
ii) $4 \times 1$ mux using Transmission gate
iii) $\mathrm{y}=A \oplus B$ Using Transmission gate
iv) 1 bit memory cell using CMOS

## OR

3. a) Design a 3-input NAND gate using CMOS such that its pull up to pull down
ratio of equivalent size is 3 .
b) Find the expression for average power dissipation of a CMOS inverter. Also
discuss how it depends on
i) Power supply $V_{D D}$ and
ii) Switching frequency $f$

## 370

Unit - IV
4. Draw the layout of following without diffusion break.
i) $\mathrm{y}=\mathrm{AB}+\mathrm{CDE}$ Using CMOS
ii) $\mathrm{y}=\mathrm{A}+B \bar{C} D$ Using CMOS

## OR

4. a) Give the reasons for
i) Using Eular path in Physical design
ii) Following DRC rule in physical design.
b) Draw the layout of a Full Adder using CMOS

Unit-V
5. Write the VHDL code for
i) Half Adder in Data flow style
ii) $2 \times 1$ mux in behavioral style
iii) 2-input XOR gate
iv) D-FF

## OR

5. a) Explain any two in VHDL
i) Data type
ii) ieee Library
iii) Delay
b) Write VHDL Code for a 4 bit register

7E 4051
B.Tech. VII Semester (Main\&Back) Examination, Dec. - 2015

Electronics \& Communication Engg.
7EC6.3(0) Operating System

Time: 3 Hours

## Instructions to Candidates:

Maximum Marks : 80
Min. Passing Marks : 24

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly).

1. a) Explain Time - I
b) Why does LINUX is a preferred choice in big companies? What is a firmware?
c) Define System Calls

## OR

1. a) What is Operating System? How does it interact with devices? What are the main agents of OS.
b) Differentiate between Single user and Multiuser system. Explain batch processing also.

## Unit - II

2. a) Explain life cycle of process and distinguish between process and Thread ( 8 )
b) Thure auc 4 processes winh $1,4,1,4$ CPU bursts and arrival time $0,2,4,5$ respectively. Compute average waiting time and average turn arround time for preemptive SJF Scheduling.

## OR

2. a) There are 4 processes with $53,17,68,24$ CPU bursts and assume time quantum as 24 unit. Calculate average waiting time and average turn arround time for round robin scheduling.
b) Which CPU Scheduling method will give the minimum average waiting time? and what is the main difficulty in its implementation.

## Unit - III

3. a) How many page faults wouid occur for the following replacement algorithm i) FIFO
ii) Optimal replacement for the string 1,2,3,4,2, 1,5,6,2,1,2,3,7,6,3,2,1,2,3,6
Three frames are allocated in main memory only.
b) Write short note on
i) Demand paging
ii) Virtual Memory Management system using page table.

## OR

3. Explain the following terms of Memory Management
i) Fragmentation
ii) Swapping
iii) Paging
iv) Segmentation
4. a) i) Explain Firewall in detail.
ii) Explain file access methods.
b) Write short note on User Authentication.
5. a) Write short notes on Implementation of files and directories management (8)
b) Differentiate among Worms, Trapdoors and Viruses.

## Unit - V

5. a) Explain Readers and Writers Problem. How it can be solved?
b) Explain Deadlock detection and recovery methods.

## OR

5. a) Consider the following Scenario of a System.

|  | A | B | C | D |
| :--- | :--- | :--- | :--- | :--- |
| $\mathrm{P}_{0}$ | 0 | 0 | 1 | 2 |
| $\mathrm{P}_{1}$ | 1 | 0 | 0 | 0 |
| $\mathrm{P}_{2}$ | 1 | 3 | 5 | 4 |
| $\mathrm{P}_{3}$ | 0 | 6 | 3 | 2 |
| $\mathrm{P}_{4}$ | 0 | 0 | 1 | 4 |

Max. Available

| A | B | C | D |
| :--- | :--- | :--- | :--- |
| 0 | 0 | 1 | 2 |
| 1 | 7 | 5 | 0 |
| 2 | 3 | 5 | 6 |
| 0 | 6 | 5 | 2 |
| 0 | 6 | 5 | 6 |

6
Answer the following questions using the Banker's Algorithm.
a) What is the content of the matrix need?
b) Is the system in a safe state.
b) What do you mean by safe and unsafe states?

Roll No.
[Total No. of Pages :
2
7E 4054
7E4054
B.Tech. VII Semester (Back) Examination, Dec. 2015

Electronics Instrumentation \& Control Engg.
7EI3(0) Computer Networks

Time : 3 Hours
Maximum Marks : 80
Min. Passing Marks : 24
Instructions to Candidates:
Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. 'ny data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly.)

## Unit - I

1. a) In $M / M / \infty$ queuing, Calculate average wait time of a packet in the queue.
2. D; Discuss the following terms briefly in context to queuing.
i) Pure birth process
ii) Pure death process
iii) Little's formula

## OR

1. a) Draw state transition diagram for $M / M / 1$ queuing system with discouraged arrivals. Calculate probability of having no packets in the queue. $\quad(4+4=8)$
2. b) Discuss $M / G / 1$ queuing system stating requisite mathematical expression. (8)

## Unit-II

․ . Discuss Go back-5 sliding window protocol taking scenario of ten equal sized packets for transinission with sixth packet lost in transit (Assume zero time out interval).
2. b) Compare briefly between packet switched network and circuit switched network by taking a suitable example for both of the cases.

## OR

2. a) Discuss different schemes of framing in the data link layer.
b) Name different protocols used for data link layer, Transport layer and Application layer. State briefly about working of these layers.

## Unit - III

3. a) Discuss static and dynamic channel allocation by stating suitable example for each of these.
4. b) Draw frame format of IEEE 802.3 protocol and discuss working of tris. (8)
OR
5. a) Describe CSMA protocol. Discuss key features of 1-perisistent, ppersistent and non-persistent CSMA protocols.
6. b) Compare pure ALOHA and slotted ALOHA by drawing \& discussing their
throughput diagrams

## Unit - IV

4. a) Draw header of $\operatorname{IPv} 4$ protocol and discuss each header detail.
5. b) Discuss any congestion control algorithm for TCP/IP networks

## OR

4. a) Compare between adaptive and non-adaptive routing algorithms.
5. b) Discuss TCP protocol architechture by drawing suitable header.
Unit - V
6. a) Draw B-ISDN ATM reference model and discuss its detail.
7. b) Draw ATM header and discuss each header detail in context to UNI and NNI.

## OR

5. a) Discuss recognition algorithm in ATM networks by drawing Suitable state diagram/flnurhart
6. b) Describe following ATM network related parameters
i) Cell loss priority
ii) Unspecified Bit rate service.
iii) Peak cell rate
iv) Cell delay variation

| 10 | Roll No. | TE4055 |
| :---: | :---: | :---: |
| 10 | B.Tech. VII Semester (Back) Examination, Dec. - 2015 |  |
| 7 | Bio Medical Enge. |  |
| 7BM6.3 Fiber Optic Instrumentation |  |  |
| Common with EIC |  |  |

Time : 3 Hours
Maximum Marks: $\mathbf{8 0}$
Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagram.s must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly.

## Unit - I

1. a) Define the following terms with respect to optical fibres:
i) Refraction
ii) Refractive Index
iii) Critical Angle
iv) Total internal reflection
b) A multimode step index fiber with a core refractive index of 1.4917 and that of claffing 1.4894 micrometer and wavelength of 1.3 micrometer
Calculate:
i) ivumuritai infiture
ii) Critical Angle of core claffing interface
iii) Number of modes

OR

1. a) Prove that for step index optical fiber, number of modes given by MSI $=\mathrm{V}^{2} / 2$ where MSI $=$ Mode volume for step index fiber and $\mathrm{V}=$ Normalized frequenc v .
b) Briefly explain the following techniques of fiber fabrication:
i) MCVD
ii) PCVD

## Unit - II

2. a) Explain the following terms for LED:
i) Life time
ii) Rise/Fall time
iii) Modulation response
iv) Output Power- Current characteristics
v) Radiated wavelength \& spectral width
b) Describe what is meant by the fusion splicing of optical fibers. Discuss the advantages and drawbacks of this jointing technique.

## OR

2. A planar LED is fabricated from GaAs which has a refractive index of 3.6
a) Calculate the optical power emitted into air as a percentage of the internal optical power for the device when the transmission factor at the crystal-air interface is 0.68
b) When the optical power generated internally is $50 \%$ of the electrical power supplied, determine the external power efficiency.

## Unit - III

3. a) Explain the following terms related to PIN Photodiode with proper expressions:
i) Cut-off wavelength
ii) Quantum Efficiency
iii) Responsivity
b) The carrier velocity in a silicon p-i-n photodiode with a $25 \mu \mathrm{~m}$ depletion layer width is $3 \times 10^{4} \mathrm{~ms}^{-1}$. Determine the maximum response time for the device.

## OR

3. a) Explain the Structure and principle of working of Avalanche photodiodes. Also deduce the expression for total current density for APD.
b) The quantum efficiency of a silicon RAPD is $80 \%$ for the detection of radiation at a wavelength of $0.9 \mu \mathrm{~m}$. When the incident optical power is $0.5 \mu \mathrm{w}$, The output current from the device is $11 \mu \mathrm{~A}$. Determine the multiplication factor of the photodiode under these conditions.
4. a) Explain different methods of measurement of refractive index profile of an optical fiber with suitable diagrams.
b) A 2 km length of multimode fiber is attached to apparatus for spectral loss measurement. The measured output voltage from the photo receiver using the full 2 km fiber length is 2.1 v at a wavelength of $0.85 \mu \mathrm{~m}$. When the fiber is then cut back to leave a 2 m length the output voltage increases to 10.7 V . Determine the attenuation per Km . For the fiber at a wavelength of $0.85 \mu \mathrm{~m}$ and Estimate the accuracy of result.

## OR

4. a) Explain the method of measurement of Numerical Aperture \& Diameter of an Optical fiber.
b) A trigonometrical measurement is performed in order to determine the numerical aperture of a step index fiber. The screen is positioned 10.0 cm from the fiber end face. When illuminated from a wide angled visible source the measured output pattern size is 6.2 cm . Calculate the approximate Numerical Aperture of the fiber.
Unit - V
5. Explain the following terms for a LASER
a) Absorption of radiation
b) Spontaneous Emission
c) Stimulated Emission
d) Population Inversion
6. Write technical notes on (Any two)
a) LASER application for measurement of distance
b) Holography
c) Q.S...ivinios
B.Tech. VII Semester (Back) Examination, Dec. - 2015

## Electronic Instrumentation \& Control Engg.

## 7EI5(O) Industrial Measurements

Time : 3 Hours
Maximum Marks : 80
Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly).

## Unit - I

1. a) A platinum thermometer has a resistance of $80 \Omega$ at $25^{\circ} \mathrm{C}$.
i) Find its resistance at $55^{\circ} \mathrm{C}$, if the platinum has a resistance temperature co-efficient of $0.00431^{\circ} \mathrm{C}$.
ii) If the thermometer has a resistance of $135^{\circ} \mathrm{C}$. Calculate the temperature.
b) Explain the construction and working of thermistors with characteristics.

## OR

1. a) A bimetallic strip element has one end fixed and other end free, with the length of cantilever being 40 mm . The thickness of each metal is 1.5 mm and the element is initially straight at $18^{\circ} \mathrm{C}$. Calculate the movement of the free end in a perpendicular direction from ine inmal lim whon the tomparatuas is raiond to $165^{\circ} \mathrm{C}$. One of the metals is invar with a negligible thermal expansion coefficient while the second is a nickel chrome alloy with an expansion coefficient of $13.6 \times 10^{-6 / 0} \mathrm{C}$.
b) Draw and explain the various characteristics of thermocouples. Discuss about its merits and demerits also.
Unit - II
2. a) Explain the working principle and applications of Piezo-electric pressure transducers with neat diagram.
b) How will you measure the pressure by differential pressure transmitters.
3. a) Explain the following:-
i) Diaphragms
ii) Bellows.
b) Explain the working and applications of capacitive pressure transducers.

## Unit - III

3. a) Explain the following:-
i) Orifice plates.
ii) Rotameters.
b) Discuss about the mass flow type meters with merits and demerits.

## OR

3. a) Explain the following:-
i) Venturi tubes.
ii) Flow nozzles.
b) Explain the construction and working of electromagnetic flow meters with suitable diagram.

## Unit - IV

4. a) Explain the impulse wheel methods for density measurement.
b) What do you mean by "Hydrostatic pressure". Explain the working of hydrostatic type level measurements.

## OR

4. Explain the following with merits and demerits:-
a) Radiation densitometer.
b) Capacitance probes.

## Unit - V

5. a) Derive the expression of Gauge factor of strain gauge. Explain the importance of Gauge factor for strain measurements.
b) What are the different adhesives and protective coatings are used in strain
gauges.
OR
6. Write shot notes on the following:-
a) Rosette strain gauges.
b) Compensation techniques of strain gauges.

# B.Tech. VII Semester (Main/Back) Examination, Dec. - 2015 <br> Applied Electronics \& Instrumentation 7AI1 Neutral Network \& Fuzzy Logic Control (Common with EIC, AI, \&BM) 

Time : $\mathbf{3}$ Hours
Maximum Marks: 80
Min. Passing Marks : 24

## Instructions to Candidates:

Attempt any five questions, selecting one question from each unit. All questions carry equal marks. (Schematic diagrams must be shown wherever necessary. Any data you feel missing suitably be assumed and stated clearly. Units of quantities used/calculated must be stated clearly.)

## Unit - I

1. a) Draw the architecture of simple perceptron network. Explain briefly perceptron learning algorithm and develop a Perceptron network to implement AND function.
b) Draw and explain Discrete Hopfield network. Give any two applications of the same.
OR
2. a) Draw and explain Mc-Culloch and Pitts Neuron architecture?
b) Explain the function of Dendrite, Soma and Axon in a biological neural network. Comporo tua opanation of biologica! noura! notwonk with artificin! nowal network. .

Unit - II
2. a) Write an algorithm for back propagation training and explain the process of updation of weights. Give the necessary formulae involved and their derivation.
b) Compare supervised learning with unsupervised learning. Give suitable examples to explain.

OR
2. a) Explain Delta learning rule.
b) Using perceptron learning rule, find the weights required to perform following classifications. Vector (1111) and (-1 1-1-1) are the members of the first class. Vectors (111-1) and ( $1-1-11$ ) are the members of second class. Use two output neurons. Assume learning rate as 0.9 and initial weight of 0.25 . Using training vectors, test the response of the net.

## Unit - III

3. a) If A is a fuzzy set defined by
$A=\left\{\frac{0.5}{X_{1}}+\frac{0.4}{X_{2}}+\frac{0.7}{X_{3}}+\frac{0.8}{X_{4}}+\frac{1}{X_{5}}\right\}$ List all the cuts and strong $\alpha$-cuts of A.
b) Two fuzzy sets are given as follows:

$$
\begin{align*}
& P=\left\{\frac{0.1}{2}+\frac{0.3}{4}+\frac{0.7}{6}+\frac{0.4}{8}+\frac{0.2}{10}\right\}  \tag{12}\\
& Q=\left\{\frac{0.1}{0.1}+\frac{0.3}{0.2}+\frac{0.3}{0.3}+\frac{0.4}{0.4}+\frac{0.5}{0.5}+\frac{0.2}{0.6}\right\} \\
& R=\left\{\frac{0.1}{0}+\frac{0.7}{0.5}+\frac{0.3}{2}\right\}
\end{align*}
$$

Perform the following operations over the fuzzy sets:
i) Two Cross Products.
ii) Max-min Composition.
iii) Max Product

## OR

3. a) Write the properties of Fuzzy set theory and explain
b) Two Fuzty sets $A$ and $B$ are defined on X as:

$$
\begin{align*}
& \underset{\sim}{A}=\left\{\frac{0.1}{X_{1}}+\frac{0.6}{X_{2}}+\frac{0.8}{X_{3}}+\frac{0.9}{X_{4}}+\frac{0.7}{X_{5}}+\frac{0.1}{X_{6}}\right\}  \tag{12}\\
& \underset{\sim}{B}=\left\{\frac{0.9}{X_{1}}+\frac{0.7}{X_{2}}+\frac{0.5}{X_{3}}+\frac{0.2}{X_{4}}+\frac{0.1}{X_{5}}+\frac{0}{\ddot{x}_{6}}\right\}
\end{align*}
$$

Explain the following $\lambda$ cut sets.
i) $\quad(A \cup B)_{0.7}$
ii) $\left(A \cap{\underset{B}{B}}_{0.7}\right.$
iii) $(\underset{\sim}{A} \cup \underset{\sim}{A})_{0.7}$
iv) $\quad(\bar{A} \cup \bar{B})_{0.7}$

## Unit - IV

4. a) Write in short about
i) Adaptive Fuzzy System
ii) Defuzzification
b) Explain the important features of the fuzzy membership function. How do the fuzzy membership function participate in Defuzzification process.
OR
5. a) Define the following:
i) Fuzzy Entropy
ii) Temporal Fuzzy logic
b) Explain in short about any two Defuzzification processes.

## Unit - V

5. a) Explain the operation of Fuzzy logic control with process inference block.(8)
b) Discuss the application of Artificial Neural network in the field of control system and optimization.

## OR

5. Design a fuzzy controller for a train approaching station. Inputs are speed and distance and output is break-power. Use triangular membership function, Consider two descriptors for input and three description for output. Device a set of rules for control action and defuzzification. The design should be supported by figures wherever possible. Design a fuzzy controller for a train with high speed and small distance.
